L Number	Hits	Search Text	DB	Time stamp
1	1666	"stopping power"	USPAT; US-PGPUB	2003/06/25 18:27
2	1206485	metal	USPAT; US-PGPUB	2003/06/25 18:27
3	509755	oxide	USPAT; US-PGPUB	2003/06/25 18:27
4	0	"stopping power" with metal with oxide	USPAT; US-PGPUB	2003/06/25 18:28
5	320008	penetrat$3	USPAT; US-PGPUB	2003/06/25 18:28
6	363354	ion or ions	USPAT; US-PGPUB	2003/06/25 18:28
7	6360	penetrat$3 with (ion or ions)	USPAT; US-PGPUB	2003/06/25 18:28
8	159688	metal with oxide	USPAT; US-PGPUB	2003/06/25 18:28
9	62	(penetrat$3 with (ion or ions)) with (metal with oxide)	USPAT; US-PGPUB	2003/06/25 18:29
10	2878292	through	USPAT; US-PGPUB	2003/06/25 18:29
11	128793	implantation or implant$3	USPAT; US-PGPUB	2003/06/25 18:29
12	28503	through with (implantation or implant$3)	USPAT; US-PGPUB	2003/06/25 18:30
13	1451	(metal with oxide) with (implantation or implant$3)	USPAT; US-PGPUB	2003/06/25 18:30
14	202	(metal with oxide) with (through with (implantation or implant$3))	USPAT; US-PGPUB	2003/06/25 18:33
15	176207	mask	USPAT; US-PGPUB	2003/06/25 18:33
16	307	mask with through with (metal with oxide)	USPAT; US-PGPUB	2003/06/25 18:37
17	48	(implantation or implant$3) with (mask with through with (metal with oxide))	USPAT; US-PGPUB	2003/06/25 18:45
18	721	"damascene gate" "dummy gate"	USPAT; US-PGPUB	2003/06/25 18:45
19	28503	(implantation or implant$3) with through	USPAT; US-PGPUB	2003/06/25 18:46
20	227	("damascene gate" "dummy gate") and ((implantation or implant$3) with through)	USPAT; US-PGPUB	2003/06/25 19:18
21	2281	through adj (implantation or implant$3)	USPAT; US-PGPUB	2003/06/25 19:19
22	5597	(implantation or implant$3) adj through	USPAT; US-PGPUB	2003/06/25 19:19
23	1504	cmp with gate	USPAT; US-PGPUB	2003/06/25 19:19
24	102	((implantation or implant$3) adj through) and (cmp with gate)	USPAT; US-PGPUB	2003/06/25 19:19
-	65379	438/$.ccls.	USPAT; US-PGPUB	2003/06/01 18:14
-	463378	semiconductor or ic or "integrated circuit" or microelectronic	USPAT; US-PGPUB	2003/05/29 17:11

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